



## ESI e3612 Asher

- True downstream 1KW to 6KW RF plasma
- Heated platen with temps up to 320 degree C
- Photoresist Removal, Descum or Oxidation
- Extremely low damage Plasma
- SMIF option
- 100mm to 200mm wafers

### Features

- e3611 single chamber TCP RF plasma
- e3612 dual chamber TCP fast Throughput
- Ethernet smart controls
- HSMS ( SECS/GEM) included
- Wafer scanner on robot
- Intuitive Touchscreen User Interface



### Advantages

- Increased Yield
- Improved Uptime
- Reduced Maintenance Costs
- Lower Cost of Ownership
- Windows 10 PC
- IDX Flexware® Software

### Why Choose ESI

- Industry Leader in Plasma Ashers
- Over 36 years of Industry Experience
- System designed for ease of use
- IDX Flexware has well established install base



ESI has been providing unique innovative upgrades, cost-effective technical solutions, high quality equipment worldwide since 1986.